

### PATENT

Case Docket No. ASMEX.367A Date: September 26, 2003

### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

Michael A. Todd

Appl. No.

10/074.534

Filed

February 11, 2002

For

PROCESS FOR DEPOSITION

OF SEMICONDUCTOR FILMS

Examiner

Shrivinas H. Rao

Group Art Unit:

2814

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

September 26, 2003

## TRANSMITTAL LETTER

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application are:

- An Information Disclosure Statement. (X)
- (X) A PTO Form 1449 with one (1) references.
- (X) The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.
- (X) Return prepaid postcard.

eph J. Mallon

Registration No. 39,287

Attorney of Record Customer No. 20,995

(619) 235-8550



# INFORMATION DISCLOSURE STATEMENT

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: Michael A. Todd

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Shrivinas H. Rao

Group Art Unit : 2814

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Enclosed is form PTO-1449 listing one (1) reference that is also enclosed.

This Information Disclosure Statement is being filed before the receipt of a first Office Action on the merits, and presumably no fee is required in accordance with 37 C.F.R. § 1.97(b)(3). If a first Office Action on the merits was mailed before the mailing date of this Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 9/26/03

Joseph I Mallon

Registration No. 39,287 Attorney of Record

Customer No. 20,995

(619) 235-8550



U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE ATTY, DOCKET NO. ASMEX.367A APPLICATION NO. 10/074,534

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

BY APPLICANT

APPLICANT Michael A. Todd

FILING DATE February 11, 2002 GROUP 2814

# U.S. PATENT DOCUMENTS EXAMINER DOCUMENT NUMBER DATE NAME CLASS SUBCLASS FILING DATE (IF APPROPRIATE)

FOREIGN PATENT DOCUMENTS									
EXAMINER		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION		
INITIAL							YES	NO	

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)					
	Todd, Michael A. et al., "Deposition of Si $_{1-X}$ Ge $_X$ Films for Gate Electrode Applications Using a Novel Approach," ICSI3, The SiGe Conference; Santa Fe, NM, March 2003					

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EXAMINER	DATE CONSIDERED					
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT,						